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Chemical vapor deposition of diamond on adamantane-coated sapphire substrate

Yi-Chun Chen and Li Chang*

Department of Materials Science and Engineering, National Chiao Tung University,

Hsinchu, Taiwan, ROC

Abstract

Continuous diamond thin films can be grown on sapphire substrates by microwave plasma chemical vapor deposition utilizing a pretreatment of adamantane dip coating on substrate for enhanced nucleation. Scanning electron microscopy, x-ray diffraction and Raman spectroscopy show that $\langle 111 \rangle$ oriented diamond films of good crystallinity can be deposited on adamantane-coated sapphire substrates. Cross-sectional transmission electron microscopy on the diamond/sapphire interface shows that diamond can be directly synthesized on sapphire without any interlayer.

Key word: adamantane, sapphire, diamond, chemical vapor deposition (CVD)

*Corresponding author: lichang@cc.nctu.edu.tw

*Address: 1001, Tahsueh Road, Department of Materials Science and Engineering,
National Chiao Tung University, Hsinchu, Taiwan 300, ROC*

Phone: +886-3-5731615, Fax: +886-3-5724727

Introduction

The synthesis of diamond films by chemical vapor deposition (CVD) has been widely demonstrated in the past few decades due to the outstanding physical and chemical properties of diamond for various technological applications.¹⁻⁴ In particular, the growth of continuous diamond thin films on optically transparent and hard substrates, such as sapphire, is important for the development of corrosion resistance and infrared windows.⁵ Diamond growth on sapphire has been studied in the past. Yoshimoto et al. have reported the nucleation and growth of diamond crystallites on sapphire by pulsed laser deposition (PLD).⁶ Chen et al. also studied the PLD growth mechanism of diamond on sapphire.⁷ Several studies for diamond growth used hot-filament chemical vapor deposition method with scratching pretreatment on sapphire to increase the nucleation density.⁸⁻¹⁰ Also, there are a few studies of the growth of diamond on sapphire coated with a buffer layer of platinum and iridium.¹¹⁻¹³ However, the growth of diamond films on optically transparent substrates like sapphire has to address several issues. For diamond growth on polished and smooth sapphire wafers, diamond nucleation is one of the most critical issues. Conventional pretreatment methods for nucleation enhancement include mechanical scratching and dc-biasing. Scratching will damage the surface of the substrate and degrade the optical properties, which is unsuitable for transparent sapphire for high

performance devices. Although Williams, O.A., et al.³³ has use the ultrasonic seeding with nanodiamond for pretreatment procedure to grow the diamond film, it does not obtain the orientation diamond film. For the dc-biasing method which has been successfully used to grow diamond directly on mirror-polished Si wafers for enhanced nucleation, it is not possible to apply to the insulating sapphire. Another critical issue for diamond growth on sapphire is that there is large thermal mismatch between diamond and sapphire due to the significant difference in their coefficients of thermal expansion, resulting in very high compressive stresses in the thin film.¹⁴⁻¹⁵ In general, the crystallinity of a diamond film can be improved with increasing film thickness and growth temperature; however, the thermal stress also increases with the thickness and the growth temperature. To obtain high quality diamond on sapphire, the film thickness will be limited by the stress which may causes cracking or delamination. Nevertheless, Singh et al. showed that low temperature growth can obtain adherent diamond films on optically transparent sapphire.²³ Several approaches, such as utilizing in-situ two-step hot filament chemical vapor deposition or polishing the substrate surface carefully and by in situ pre-deposition of a carbon layer on the alumina substrate surface, or using the activated species transport (AST) method which supplies activated diamond species to the substrate in a plasma flame, were proposed to overcome the problem, but they still resulted in a relatively low

nucleation density ($\sim 10^6$ – 10^7 particles/cm²).¹⁶⁻²⁰

We have previously shown enhanced nucleation of diamond on adamantane-coated Si at relatively low temperatures²¹⁻²² which may mitigate the thermal stress. In this work, we report the application of a pretreatment method of adamantane coating on sapphire substrate for diamond film growth by chemical vapor deposition (CVD).

Adamantane (C₁₀H₁₆) consists of 10 carbon atoms arranged as a single diamond cage surrounded by 16 hydrogen atoms. The spatial arrangement of carbon atoms in adamantane molecule is the same as that in diamond crystal. In other words, an adamantane molecule can be regarded as a sub-nanometer sized unit of diamond crystal. Here, we show that coating of adamantane on sapphire can be an effective method to grow diamond on flat sapphire surface.

Experimental

Commercially available 2-inch c-plane sapphire wafers were cut into a dimension of 1 x 1 cm² as substrate. The substrates without any mechanical pretreatment were ultrasonically cleaned with acetone for 10 minutes, and dried with nitrogen gas. Then, the substrates were dip-coated in an ethylene glycol solution with adamantane powder (purity > 99%) at room temperature. The glycol has been proved

to be effective to reduce the evaporation of adamantane which has a high vapor pressure at room temperature.²² The concentration of the solution was 1 g adamantane per 10 ml solvent. The dip coating conditions were similar to those used for Si substrate which had been described in detail elsewhere.²²

The adamantane-coated sapphire substrates were placed on a Mo holder for diamond growth in an AsTeX-type MPCVD system.²⁴ The diamond films were grown at a gas pressure of 50 torr and microwave power of 800 W for various periods from 15 min to 48 h. The diamond films were formed at a fixed total gas flow rate of 300 sccm and in the gas mixture containing H₂ and CH₄ with a CH₄/H₂ ratio of 0.3/99.7. The substrate temperature during the deposition was roughly estimated to be 700°C as measured by optical pyrometer.

The surface morphology was examined in a field emission scanning electron microscope (SEM, JEOL JSM-6500F). The crystallinity of diamond was evaluated with x-ray diffraction (XRD) and Raman spectroscopy. XRD patterns were acquired from a Bruker D2 XRD system using Cu K α x-rays. Raman spectroscopy was performed in a LABRAM HR800 system, which allowed the 488 nm laser beam be focused to 1 μ m diameter for micro-mode operation. The film microstructure and the interface were characterized using transmission electron microscopy (TEM, FEI Tecnai30F operated at 300 kV). Focused ion beam (FIB, Seiko Instruments SMI

3050SE) was used for cross-sectional TEM specimen preparation.

Results and discussion

After dip-coating of adamantane on sapphire substrate, the adamantane-coated sapphire substrates were placed in a MPCVD reactor for diamond deposition. Fig. 1(a) shows the top view surface morphologies of a deposited diamond film on the sapphire substrate after 48 h growth. The diamond grains have an average size in $\sim 10 \mu\text{m}$. In the high magnification image as shown in Fig. 1(b), it can be clearly seen that the surface morphology of the synthesized diamond exhibits triangular and hexagonal shapes which are the typical appearance of diamond $\{111\}$ facets. The thickness of the continuous diamond film is $\sim 10 \mu\text{m}$ as shown in Fig. 1(c) in cross section view, giving the growth rate of diamond of $0.2 \mu\text{m/h}$. Fig. 1(d) shows a Raman spectrum of the diamond film on sapphire. The Raman peak at 1332 cm^{-1} confirms the successful deposition of the diamond film on sapphire, and the full width at half-maximum (FWHM) of the peak is determined to be 8 cm^{-1} , implying a good crystallinity for the film. A broad band exists at $\sim 1550 \text{ cm}^{-1}$ with a relatively lower intensity, suggesting the presence of a small amount of graphite. To make sure the effectiveness of adamantane dip coating for diamond nucleation, we have grown the diamond on the sapphire without coating adamantane under the same deposition condition for

comparison. Also, to distinguish the role of adamantane from glycol on diamond nucleation in synthesis, we have examined the surface morphology of the substrate dip-coated in the pure solvent without any addition of adamantane after diamond deposition in the same MPCVD condition. The morphology on sapphire without coating adamantane is shown in Fig. 2(a) that most of the areas are rarely observed with diamond particles. The morphology of sapphire covered with dry-coated adamantane powder and the morphology of sapphire only dip-coated with glycol solvent without any addition of adamantane are shown as Fig. 2(b) and Fig. 2(c). Thus, it clearly indicates that the adamantane coating can enhance the yield of diamond deposition. However, we have not clear clues about whether adamantane directly transforms to diamond or decompose into carbon-containing radicals.

To understand the evolution of the diamond deposition on adamantane-coated sapphire substrate, the deposition time was varied from 15 - 360 min with the same plasma condition. The SEM surface morphologies are shown in Fig. 3. For the 15 min deposition, only a few diamond particles in 1-2 μm size are seen to form on sapphire (Figs. 3(a) and (b)) from which the nucleation density is estimated to be about $1 \times 10^7 \text{ cm}^{-2}$. In Figs. 3(c) and (d), the number of diamond particles significantly increases after deposition for 30 min (the nucleation density $\sim 1 \times 10^8 \text{ cm}^{-2}$), indicating that the diamond nucleation density still increases with deposition time. After deposition for

about 60 min, a continuous diamond film can form in some local areas. For the 360 min growth, a continuous diamond film has formed on the whole surface of sapphire substrate. The samples deposited for 15 - 360 min were also evaluated with Raman spectroscopy as shown in Fig. 4. In all cases, the diamond peak at 1332 cm^{-1} is clearly observed in addition to the disordered graphitic peak at 1580 cm^{-1} . For the 15 min deposition, a weak peak at 1150 cm^{-1} is additionally observed, which can be attributed to the nanodiamond signal²⁵⁻²⁶. Figure 5 shows XRD patterns of the diamond films grown on sapphire for the different deposition times. In addition to sapphire (0006) peaks, the XRD patterns in Fig. 5 present sharp and well-defined peaks at $2\theta = 43.9$ and 75.7° corresponding to diamond {111} and {220} reflections, respectively, for growth time reaching 60 min and above, indicating that the deposited amount of diamond is increased above the detection limit of XRD in consistence with SEM observations.

Furthermore, the cross-sectional TEM specimen of a diamond sample deposited on sapphire for 2 h was prepared by FIB. For the protection of the TEM specimen against damage from the high-energy ion beam in FIB, the specimen was coated with platinum before FIB cutting. The cross-sectional bright-field TEM image and the selected area electron diffraction (SAED) pattern from the marked regions of diamond and sapphire are shown in Fig. 6. The TEM image in Fig. 6(a) shows that the diamond

crystallite is in twin characteristics for the left and right halves which also can be identified from the SAED patterns in Figs. 6(b)-(e) from the individual regions in Fig. 6. Also, it can be seen that the sapphire surface remains smooth after diamond deposition, implying that the sapphire has undergone negligible etching by the plasma. The SAED patterns in Figs. 6(b)-(d) obtained from the corresponding marked regions show the single crystalline diamond characteristics in $\langle 110 \rangle$ zone axis and sapphire in $\langle 2\bar{1}\bar{1}0 \rangle$ one. The SAED patterns in Figs. 6(b) and (c) indicate that the left diamond is $\langle 001 \rangle$ oriented and the right one is $\langle 111 \rangle$ oriented, and they are in the twin relationship. The SAED pattern in Fig. 6(e) from the interface region shows that the orientation relationship is closed to $\langle 110 \rangle_{\text{diamond}} // \langle 2\bar{1}\bar{1}0 \rangle_{\text{sapphire}}$ and $\{111\}_{\text{diamond}} // \{0001\}_{\text{sapphire}}$ or $\{111\}_{\text{diamond}} // \{0\bar{1}14\}_{\text{sapphire}}$. This is different from the in-plane epitaxial relationship of $\langle 110 \rangle_{\text{diamond}} // \langle 1\bar{1}00 \rangle_{\text{sapphire}}$ which has been reported in literature.^{6, 27, 28} The lattice mismatch of diamond along $\langle 110 \rangle$ with sapphire along $\langle 2\bar{1}\bar{1}0 \rangle$ is about 6% (5.04 Å versus 4.76 Å), in comparison with that of ~ 39% with sapphire along $\langle 1\bar{1}00 \rangle$ (8.24 Å). Only reflections of diamond and sapphire can be observed in Fig. 6(e) without any other additional diffraction reflections, suggesting that no crystalline interlayers exist between them and no extra crystalline phases in diamond. The HRTEM image in Fig. 6(f) is obtained from an interfacial region between diamond and sapphire (the

left-hand side region of the image with zone axis in $\langle 2\bar{1}\bar{1}0 \rangle$ sapphire), showing diamond and sapphire lattice fringes. The d-spacing between the fringes in the diamond region is 2.06 Å which corresponds to be the diamond {111} interplanar spacing, consistent with the SAED observations as shown in Figs. 6(b). As the diamond fringes are in connection with the sapphire ones, we can observe no interlayer formed between the diamond and the sapphire, suggesting that the diamond film was directly grown on the sapphire. As shown in Fig. 6(g), the filtered image after inverse fast Fourier transform (FFT) of the lattice image using diamond (111) and sapphire (0 $\bar{1}$ 14) reflections illustrates a reasonably good match of diamond (111) with sapphire (0 $\bar{1}$ 14) due to their close domain matching in 5:4 (d-spacings 2.06 Å vs 2.55 Å), consistent with the result obtained from the SAED pattern in Fig. 6(e). Such domain matching has been often found in heteroepitaxy of thin film growth.²⁹ Thus, it is suggested that diamond can be epitaxially grown on sapphire.

Although Tiwari et al.³⁰ have proposed the hydrogen abstraction as one of the possible mechanisms for diamond nucleation in the gas phase sublimated and mixed in the gaseous plasma which then deposited on the Si surface, it is worthwhile to briefly discuss the possible mechanisms for diamond nucleation and growth from adamantane on sapphire. It has been suggested that adamantane might be able to serve as embryo for nucleation of diamond in the gas phase as adamantane is easily

evaporated at high temperature and decompose into individual molecules.^{21,31} When adamantane was in touch with plasma from gaseous (0.3% CH₄ in H₂) phase, it might decompose into hydrocarbon species. These species might convert to nanosized diamond particles in the gas phase. Then the particles deposited on the substrate surface might act as nuclei for subsequent growth of diamond on sapphire. Additionally, the hydrogen abstraction can be one of the possible mechanisms for diamond nucleation in the gas phase as adamantane can be considered as diamond nucleus covered with hydrogen atoms, and then methane gas species in hydrogen plasma may facilitate the growth of three dimensionally individual nuclei.³⁰ Alternatively, some residual adamantane left on the substrate surface might be able to be directly converted to nanodiamond. Our previous study have shown that adamantane can adhere on Si through the OH-bond of glycol.²² Toshinari et al.³² have coated octadecyltrichlorosilane on the (0001) sapphire. It shows that the octadecyltrichlorosilane is covalently bound to the OH-terminated surface of sapphire. Therefore, the adamantane in glycol may bond with sapphire by C₁₀H₁₆-OH-O-Al bonds similar to the bonding on Si. As a result, the sticking of adamantane with the sapphire surface is enhanced, and its evaporation or sublimation is reduced, which can increase the chance for adamantane to remain on the surface and act as embryo for diamond nucleation.

Conclusions

In summary, we demonstrate a simple method for the direct synthesis of good quality and highly crystalline diamond films on adamantane-coated sapphire substrate by microwave plasma chemical vapor deposition. The results from SEM, XRD, and Raman spectroscopy show that the adamantane assists the diamond nucleation and a $\langle 111 \rangle$ oriented continuous diamond film on sapphire can be obtained. TEM examinations with electron diffraction analysis also confirm that the interface between diamond and sapphire is smooth with no interlayer formation, and an orientation relationship of diamond with sapphire is identified as $\langle 110 \rangle_{\text{diamond}} // \langle 2\bar{1}\bar{1}0 \rangle_{\text{sapphire}}$ and $\{111\}_{\text{diamond}} // \{0001\}_{\text{sapphire}}$.

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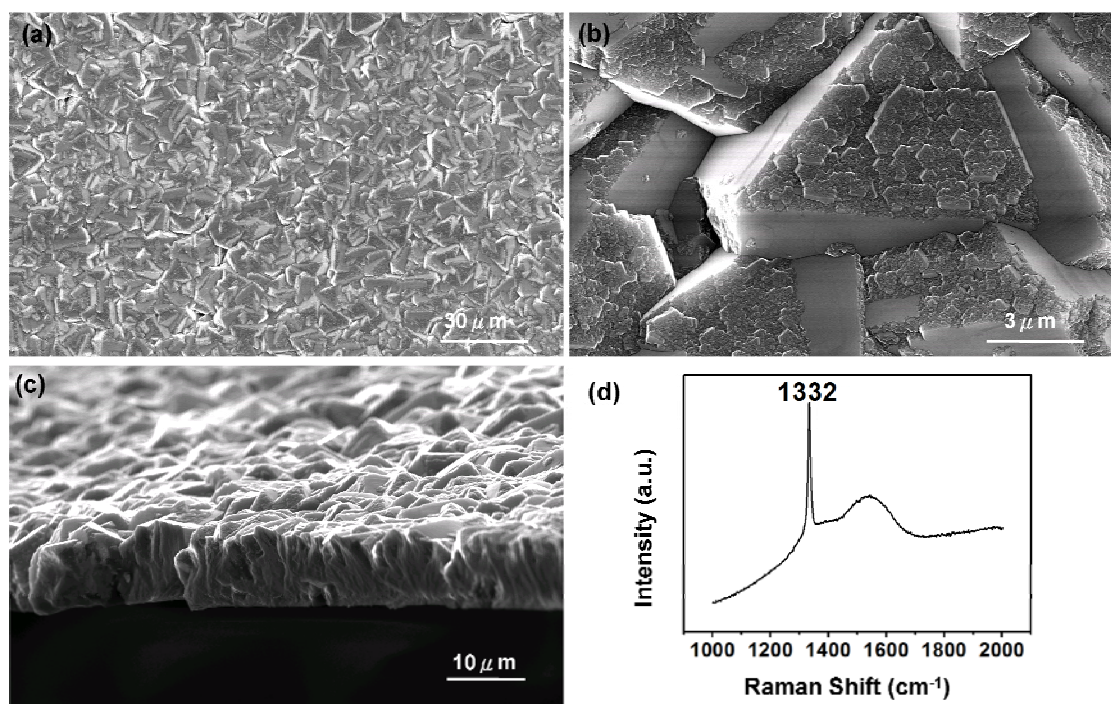
Figure captions

Figure 1. SEM images of synthesized diamond films on sapphire for 48 hr in (a) low magnification in plan-view, and (b) high magnification in plan-view, and (c) in cross section. (d) Raman spectrum.

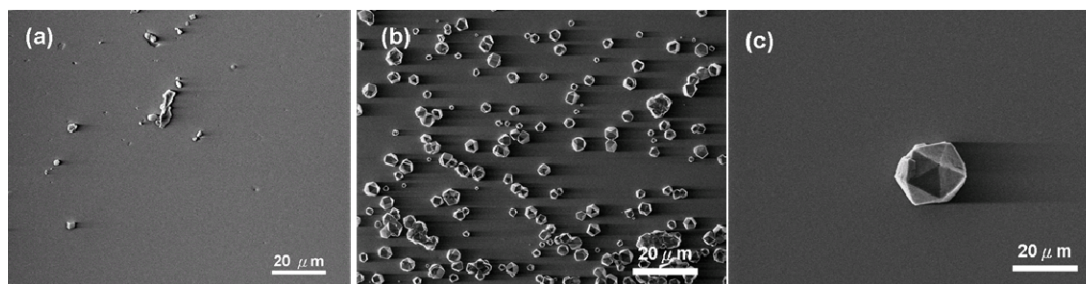


Figure 2. SEM surface morphology after CVD (a) on uncoated sapphire, (b) on sapphire cover with dry-coated adamantane powder, and (c) on sapphire only dip-coated with glycol solvent without any addition of adamantane.

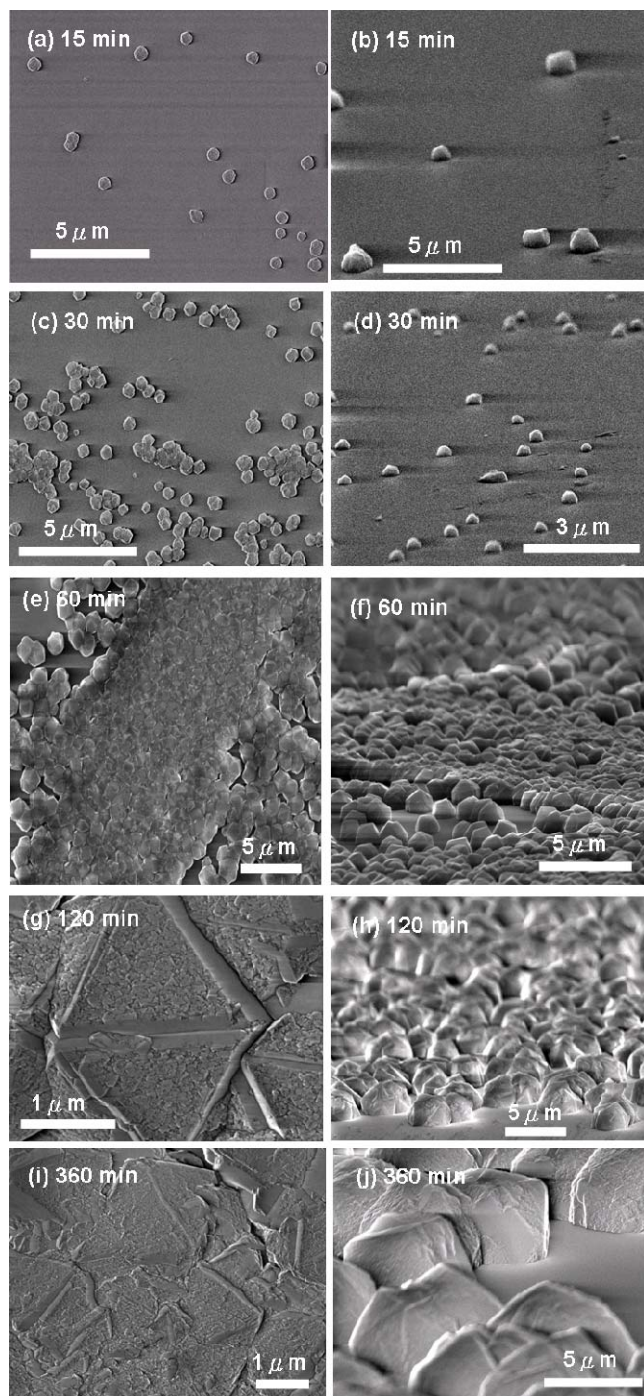


Figure 3. SEM of diamond films on sapphire for different growth time in plan-view on the left column and cross-section view on the right column. (a) and (b) 15 min, (c) and (d) 30 min, (e) and (f) 60 min, (g) and (h) 120 min, and (i) and (j) 360 min.

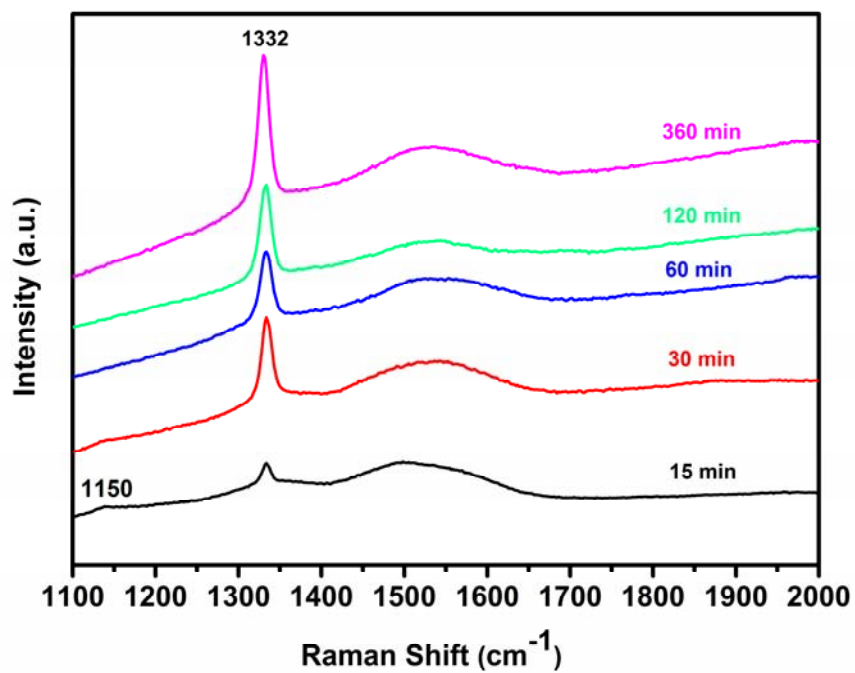


Figure 4. Raman spectra of diamond films on sapphire for 15 - 360 min growth.

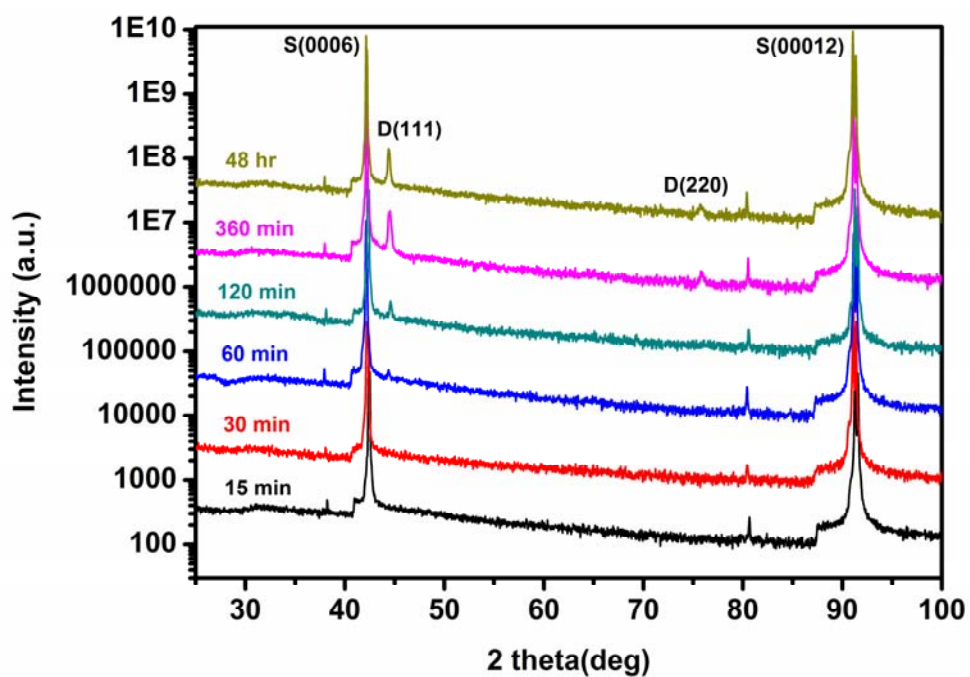


Figure 5. XRD patterns of diamond films grown on sapphire for growth from 15 min to 48 hr.

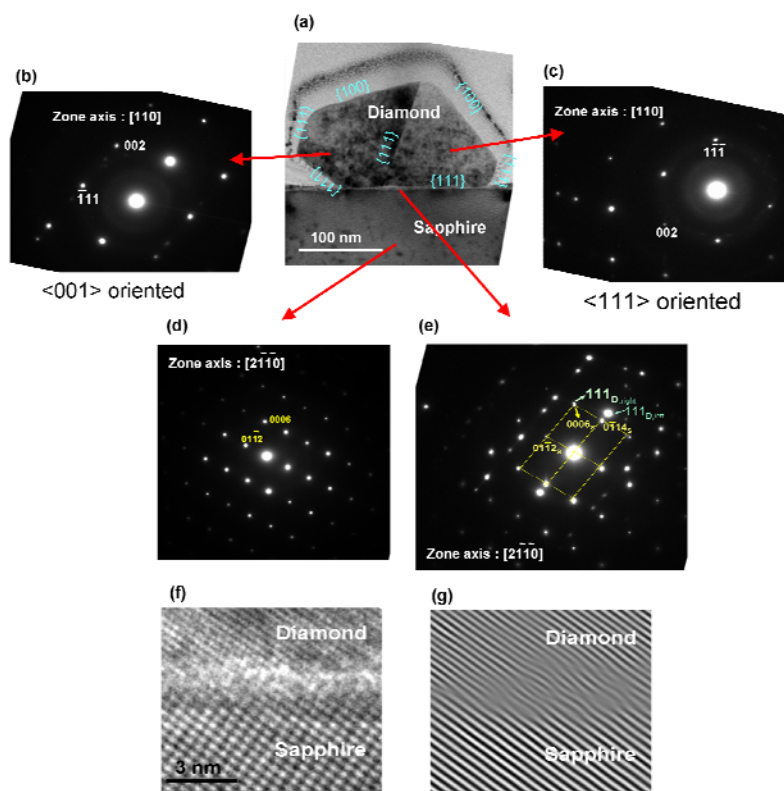


Figure 6 The Cross-sectional BF-TEM image of diamond on sapphire and the corresponding SAED patterns from diamond and sapphire regions. (a) BF TEM, (b) (c) SAED patterns of diamond from left and right hand sides, respectively, (d) SAEDP of sapphire. (e) SAEDP at the diamond/sapphire interface, (f) HRTEM image of the interface between diamond (left) and sapphire with (g) inverse FFT-filtered image of diamond (111) and sapphire ($0\bar{1}14$).